## Please amend Page 10, lines 12-22, as follows:

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The imaging circuit may further comprise means for comparing signals from pixels of the detectors with an upper or lower limit of a dynamic range of the reading circuit, means for generating variation data of the detectors based on the result of the comparison, and means for manipulating a most significant bit (MSB) of each of the variation data of the detectors to determine a value of the MSB based on the result of the comparison, and successively manipulating bits of the variation data of the detectors to determine values of the bits up to a least significant bit thereof.

# Please amend Page 15, lines 22-26 continuing to page 16, lines 1-16, as follows:

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The emitter sizes (m) of the NPN transistors 116 are different for the following reasons: The relationship between the base current  $I_B$  and the base-to-emitter voltage  $V_{BE}$  is expressed by

$$I_{B} = mIB_{0}Exp[qV_{BE}/kT]$$

where  $IB_0$  represents a reverse leakage current, q a unit charge, k the Boltzmann's constant, and T the absolute temperature. Since the base current is expressed by  $I_B = I_c/\beta$  where  $\beta$  is the current amplification factor, if the collector current changed with the emitter size m being constant, the base-to-emitter voltage  $V_{BE}$  would also change. Because the same voltage  $V_{bI}$  is applied to the bases of the transistors 116, if the base-to-emitter voltage  $V_{BE}$  were different from state to state, the currents in the respective stages would not be established as described above. By changing the emitter size m depending on the current, the base-to-emitter voltages  $V_{BE}$  in the respective stages become equal to each other, and currents in the respective stages



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can be established as described above.

### Please amend Page 17, lines 14-26 continuing to page 18, lines 1-5, as follows:



The total noise can be reduced by increasing the emitter resistance. If the emitter resistance is increased to 1 K $\Omega$  or more, the total noise starts to decrease. If the emitter resistance is 5 K $\Omega$  or higher, the total noise is about 3 dB lower than if the emitter resistance is 1 K $\Omega$  or less. The value of 3 dB is a limit value at which the human eye can recognize the improved total noise. When the collector current is 10  $\mu$ A, then the voltage across the emitter resistance is 5 V or lower if the emitter resistance is 500 k $\Omega$  or less, and can be handled by an ordinary BiCMOS circuit. If the emitter resistance is 100 k $\Omega$  or less, then the voltage across the emitter resistance is 1 V or less, providing a margin to the dynamic range of the circuit. Therefore, the emitter resistance should range from 1 k $\Omega$  to 500 k $\Omega$ , preferably from 5 k $\Omega$  to 100 k $\Omega$ .

# Please amend page 18, lines 18-26 continuing to page 19, lines 1-10, as follows:



In order to reduce temperature drifts of the imaging device, it is necessary to reduce the temperature dependency of the currents  $I_0$ , 2  $I_0$ , 4  $I_0$ , . . . of the FPN correction regulated constant-current source 113. To meet this requirement, a base voltage  $V_{b3}$  serving as a basis for the currents  $I_0$ , 2  $I_0$ , 4  $I_0$ , . . . is designed so as to be less temperature dependent. The base voltage  $V_{b3}$  may be generated within or supplied from outside of the FPN correction regulated constant-current source 113. For reduced temperature dependency, however, it is preferable to use a regulated constant-voltage source having a very small temperature dependency

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property such as a band gap reference or the like for generating the base voltage  $V_{b3}$ . In infrared imaging device applications, such a regulated constant-voltage source may be formed on a chip for a constant temperature because the chip may be or kept at a normal temperature by a Peltier device.

### Please amend page 30, lines 8-20 as follows:



Fig. 8 shows a process of generating the FPN correction data. It is assumed that the number of bits of the FPM correction data is 3. The process shown in Fig. 8 comprises a step 601 of clearing data of all addresses of the FPN memory 513, a step 602 of changing bit positions from most significant bit (MSB) to least significant bit (LSB), a step 603 of setting a bit b of all addresses of the FPN memory 513 to 1, an instruction step 604 for changing V addresses, an instruction step 605 of changing H addresses, a step 606 of making a conditional jump based on the decision made by the comparator 511, and a step 607 of resetting a bit b of a certain address of the FPN memory 513 to 0.

#### **IN THE CLAIMS:**

#### Please amend claims 1, 11-14, and 20-22 to read as follows:

1. (Amended) An imaging device comprising:



a plurality of detectors for converting an electromagnetic radiation into electric signals;

a plurality of read circuits, each connected to at least one of said detectors, and including a first regulated constant-current source for supplying a constant bias current to said